Conta

(b) a modular optical inspection system including

a plurality of modular inspection subsystems each configured to detect defects on a portion of a semiconductor wafer, [and]

a mechanism for moving at least one of the semiconductor wafer and the plurality of modular inspection subsystems with respect to one another, and

a master processor configured to process data delivered from at least some of the modular inspection subsystems, wherein a first one of the plurality of modular inspection subsystems includes a local processor configured to process data collected by the first modular inspection subsystem; and

(c) a handling tool for moving the semiconductor wafers among the plurality of manufacturing tools and the inspection system.

REMARKS

Applicant believes that all pending claims are allowable and respectfully requests a Notice of Allowance for this application from the Examiner. Should the Examiner believe that a telephone conference would expedite the prosecution of this application, the undersigned can be reached at the telephone number set out below.

Respectfully submitted, BEYER & WEAVER, LLP

Joy M num

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